

UNITED STATES PATENT AND TRADEMARK OFFICE
CERTIFICATE OF CORRECTION

PATENT NO. : 7,199,060 B2
APPLICATION NO. : 10/724141
DATED : April 3, 2007
INVENTOR(S) : Schwalbe et al.

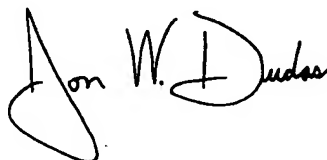
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It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

In Col. 9, line 58, delete "2000°C." and insert --200°C.--.
In Col. 9, line 66, delete "lost" and insert --loss--.
In Col. 10, line 21, delete "avid" and insert --acid--.
In Col. 10, line 25, delete "cried" and insert --carried--.
In Col. 10, line 33, delete "resist photosensitive" and insert --photosensitive resist--.
In Col. 10, line 34, delete "a resist" and insert --a photosensitive resist--.
In Col. 10, line 48, delete "lost" and insert --loss--.
In Col. 11, line 18, delete "so that a patterned dielectric layer is obtained" and insert --obtained--.
In Col. 11, line 19, delete "lost" and insert --loss--.

Signed and Sealed this

Eighteenth Day of September, 2007

A handwritten signature in black ink, appearing to read "Jon W. Dudas". The signature is stylized with a large, looping initial "J" and a distinct "D".

JON W. DUDAS
Director of the United States Patent and Trademark Office